Influence of deposition temperature on nanocrystalline CdS thin films: Application in Solar Cells as Antireflection Coatings

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ABSTRACT

Nanocrystalline CdS thin films were successfully prepared using simple chemical bath deposition technique. Cadmium sulphate, thiourea and deionised water were used as starting precursor solution. The prepared thin films were characterized using X-ray diffractogram (XRD), Scanning electron microscope (SEM), elemental composition using energy dispersive spectrophotometer (EDAX) and optical band gap (UV-Spectroscopy). X-ray diffractogram reveals that present of cubic and hexagonal phase. The thickness, crystallite size and grain size were observed to be increase with increase operating temperature of bath while optical band gap energy slightly decreases. Effect of deposition temperature on physical, structural, microstructural, electrical and optical properties of these films was studied and presented in the present investigation. Prepared thin films shows good response towards photoconducting in presence and absent of light.

Keywords: CdS thin films; XRD; SEM; TEP and electrical conductivity

1. INTRODUCTION

Semiconducting thin films of CdS are used in commercial photocells and also as window material for CdS/CdTe solar cells continues as a subject of intense research in order to obtain cells with higher efficiencies [1]. CdS thin films are regarded as one of the most promising materials for heterojunction thin film solar cells. Wide band CdS ($E_g = 2.42$ eV) has been used as the window material together with several semiconductors such as CdTe, Cu_2S and InP with 14-16 % efficiency [2-5]. Various techniques, have been employed to prepare CdS thin films such as thermal evaporation [3], sputtering [4], molecular beam epitaxy [5], spray pyrolysis [6], chemical bath deposition [7]. Chemical bath deposition is a method of growing thin films of certain materials on a substrate immersed in an aqueous bath containing appropriate reagents at temperatures ranging from room temperature to 100 °C. It has been identified as a low process suitable for the preparation of large area thin films [8]. Chemical bath deposition (CBD) method has attracted much attention since it is conformed as a simple and promising technique to obtain device quality films. CBD is a simple which is also used to deposited the semiconductor on photovoltaic device. The CBD method appears suitable for large area industrial process because it is the least expensive and a low temperature method. The deposited films samples were characterized by XRD, SEM, UV-

spectroscopy and electrical techniques. This work investigate effect of deposition temperature on physical, structural, microstructural, electrical and optical properties of these films .The films were characterized using different analytical techniques. The results were discussed and interpreted in the present investigations.

2. EXPERIMENTAL WORK

2. 1. Substrate cleaning

The substrate cleaning is very important in the deposition of thin films. Commercially available glass slides with a size of $25\text{ mm} \times 25\text{ mm} \times 1\text{ mm}$ were washed using soap solution and subsequently kept in hot chromic acid and then cleaned with deionized water followed by rinsing in acetone. Finally, the substrates were previously cleaned with deionized water for 20 min and wiped with acetone and stored in a hot oven [11].

2. 2. Preparation of nanocrystalline CdS thin films

Fig. 1. Chemical bath deposition set up.

The chemical bath deposition technique was used to deposit the thin films of cadmium sulphide on glass substrate (Shows in Fig. 1). The starting materials used were cadmium sulphate and thiourea. Triethanolamine (TEA) was used as a complexing agent. Ammonia solutions were used to adjust pH of the reaction mixture. In order to obtain good quality of thin films, following parameter were adjust such as time, temperature of deposition and pH of the solution. The optimum value of time, temperature and pH were tabulated in Table 1.

Table 1. Optimum parameter to obtain nanocrystalline CdS thin films.

Deposition parameter	Optimum value / item
Deposition time	70 min
pH	10
Concentration of precursor Cadmium sulphate, Thiourea	0.1 M
Solvent	Deionized water
Deposition temperature	60 °C, 65 °C,, 70 °C, and 75 °C,

2. 3. Post preparative treatment of CdS thin films

The as prepared CdS thin film samples were fired at 225 °C for 10 min.

3. CHARACTERIZATIONS OF THIN FILMS

3. 1. Physical Properties

The film thickness was measured by a weight difference method [12-15] in which weight of the sample, area and densities were considered.

3. 2. Structural properties using XRD

The CdS thin film were characterized by X-ray diffraction ((Miniflex Model, Rigaku, Japan)) using $\text{CuK}\alpha$ radiation with a wavelength, $\lambda = 1.542 \text{ \AA}$. The average grain size of CdS thin film samples were calculated by using the Scherrer formula

$$D = 0.9\lambda/\beta\cos\theta \quad \text{----- (1)}$$

where:

D = Average crystallite size

λ = X-ray wavelength (1.542 Å)

β = FWHM of the peak

θ = Diffraction peak position.

3. 3. Microstructural properties using SEM

The microstructure and element composition of the films was analyzed using scanning electron microscope coupled with energy dispersive spectrophotometer (JEOL 2300 model, Japan).

3. 4. Optical properties using UV-spectroscopy

The optical properties of the films were measured using UV-visible-2450 spectrophotometer at room temperature.

3. 5. Electrical properties

Electrical conductivity measured using two probe method (SES Instrument Model: PID-210, Model: EHT-11). Thermoelectric power measurement were conducting using TEP setup (Pushpa agencies).

4. RESULT AND DISCUSSION

4. 1. Physical properties

4. 1. 1. Determination of film thickness

The thickness, sample weight and sample area are related as:

$$t = M/A \cdot \rho \quad \text{----- (2)}$$

where:

M = weight of the sample in gm ,

A = area of the sample in cm^2

ρ = materials density in $gm\ cm^{-3}$

The thickness of the film was 650-705 nm. The values of the film thickness with grain size are given in Figure 2.

Fig. 2. Thickness of the films as a function of deposition temperature.

The Thickness of the films increases with deposition temperature as shown in Figure 2. The linear increasing thickness with deposition temperature could be due to the change in crystallite size and grain size accompanied with deposition temperature.

4. 2. Structural properties

4. 2. 1. Crystal structure and size

Figure 3 shows the X-ray diffractogram of pattern of the film prepared at different operating temperature (60 °C - 75 °C). It shows presence of different strong diffraction peaks which confirm mixed phases of cubic and hexagonal CdS formation. The large number of peaks indicates the crystalline nature of the CdS film sample. From the XRD spectrum it is clear that CdS film sample deposited in the cubic and hexagonal phases. The observed d-values which coincide well with the JCPDS data [16,17]. 'hkl' planes of cubic phase is shown in the Fig. 3 with symbol (C= cubic) faces while the 'hkl' planes of hexagonal phase is shown in the symbol (H= hexagonal) faces. X-ray analysis showed that CdS films are crystalline in nature with cubic and hexagonal modification.

Fig. 3. X-ray diffractogram of nanocrystalline CdS thin film samples: S1, S2, S3 and S4.

The increase in the intensity of peak is observed at 40° due to merging of peaks of cubic and hexagonal phases takes place. Similarly the increase in the intensity of peak is observed at 67° due to merging of peaks of cubic and hexagonal phases takes place. From the full-width at half-maximum of the diffraction peaks, the average sizes of the nanocrystallites (Table 1) have been calculated using the Debye-Scherrer formula [11].

Peak intensity of the films was observed to be maximum for sample (S4) at operating temperature 105°C . While it is minimum for the film prepared at operating temperature 60°C , due to low deposition temperature. From Fig. 3 as deposition temperature increases, crystallite size increases. These results show that the size of the CdS nanocrystallites depends mainly on the deposition temperature and it increases with increasing the deposition temperature (the size of nanocrystallites change from 23 nm at 60°C to 42 nm at 105°C).

This deposition temperature dependence of size may be explained according to that the larger crystallites being more stable than the smaller ones which are formed at the initial deposition time.

The lattice parameters of cubic and hexagonal phases have been calculated by using equation (3) and (4) respectively.

$$a = d(h + k + l)^{1/2} \text{ ----- (3)}$$

$$1/d^2_{hkl} = 4/3[h^2 + hk + k^2]/a^2 + 1/c^2 \text{ ----- (4)}$$

where 'd' is the interplanar distance and 'h, k, l' are Miller indices of the lattice planes.

The lattice parameter 'a' of cubic phase was found to be in the order of 5.848 Å. The lattice parameter 'a' and 'b' of hexagonal phase were found to be in the order of 4.1338 Å and 7.7127 Å respectively. The structural parameters of Cubic phase are shown in Table 2 while structural parameters of hexagonal phase are shown in Table 3.

Table 2. Comparison of standard d values with observed d values and cell parameter for cubic phase.

hkl plane	Standard d-values Å Cubic phase	Observed d-values Å Cubic phase				Cell parameter (Å) a 6.776			
		S1	S2	S3	S4	S1	S2	S3	S4
111	3.360	3.354	3.355	3.355	3.359	5.846	5.847	5.849	5.848
200	2.900	2.899	2.896	2.897	2.998				
220	2.060	2.056	2.058	2.059	2.057				

Table 3. Comparison of standard d values with observed d values and cell parameter for hexagonal phase.

hkl plane	Standard d-values Å hexagonal phase	Observed d-values Å Cubic phase				Cell parameter (Å) a and c			
		S1	S2	S3	S4	S1	S2	S3	S4
100	3.560	3.358	3.357	3.359	3.356	4.13 (a) 7.71 (c)	4.12 (a) 7.70 (c)	4.13 (a) 7.69 (c)	4.14 (a) 7.72 (c)
002	3.350	3.347	3.349	3.346	3.348				
101	3.140	3.138	3.136	3.137	3.139				
102	2.450	2.449	2.447	2.448	2.446				
110	2.070	2.068	2.069	2.067	2.066				

4. 3. Optical properties study using UV-Spectroscopy

Fig. 4. Plot of the $(\alpha h\nu)^2$ vs photon energy ($h\nu$) for nanocrystalline CdS thin film.

The optical energy band gap of CdS thin film was estimated from optical absorption measurement. The optical absorption spectrum for the CdS thin film is recorded in the wavelength range of 300-900 nm at room temperature shown in Fig 4. The optical absorption data were analyzed using the following classical relation of optical absorption in semiconductor near band edge:

$$\alpha h\nu = A(h\nu - E_g)^n \text{ -----(5)}$$

where α is absorption coefficient, A is constant, E_g is the separation between bottom of the conduction band and top of the valence band, $h\nu$ the photon energy and n is a constant.

The value of n depends on the probability of transition; it takes values as 1/2, 3/2, 2 and 3 for direct allowed, direct forbidden, indirect allowed and indirect forbidden transition respectively. Thus, if plot of $(\alpha h\nu)^2$ versus $(h\nu)$ is linear the transition is direct allowed. Extrapolation, of the straight-line portion to zero absorption coefficient ($\alpha = 0$), leads to estimation of band gap energy (E_g) values. Fig. 4 shows variation of $(\alpha h\nu)^2$ as a function of photon energy ($h\nu$). The band gap energy, calculated from the spectrum for film was tabulated in Table 3. This suggests the decrease in the band gap energy (E_g) with increasing the deposition time. It is strongly observed that the CdS thin films exhibit the least reflectance for almost all wavelengths. From the above studies, it is believed that the CdS thin films may be used as an antireflection coating material for thin film solar cells.

4. 4. Microstructural Properties

4. 4. 1. Scanning electron microscope

Fig. 5 shows the SEM images of CdS thin film samples S1, S2, S3 and S4 respectively.

(a)

(b)

(c)

(d)

Fig. 5. SEM images of nanocrystalline CdS thin film samples: (a) S1, (b) S2, (c) S3 and (d) S4.

Table 4. Measurement of deposition temperature, film thickness, crystallite size, grain sizes and optical band gap energy.

Sample	Deposition temperature (°C)	Thickness (nm)	Calculated crystallite size from XRD (nm)	Observed grain size from SEM (nm)	Optical band gap energy (eV)
S1	60	650	23	24	3.40
S2	65	677	29	30	3.34
S3	70	693	39	40	3.29
S4	75	705	42	44	3.23

4. 5. Quantitative element analysis (EDAX)

Table 5. Quantative elemental analysis as prepared CdS thin film.

[illegible]

Fig. 6 shows the elemental analysis of CdS thin film (sample S3). It was analysed using an energy dispersive spectrophotometer.

Fig. 6. Elemental analysis of CdS thin film sample (S3).

4. 6. Electrical properties

4. 6. 1. Thermoemf measurement

Fig. 7. Thermoemf of nanocrystalline CdS thin films.

In order to decide the type of charge carrier, thermoelectric measurement was taken. The graph of TEP Vs Temperature (K) is as shown in Fig 7. In the thermoemf measurement the temperature difference causes the transport of carriers from hot end to cold end and thus creates an electric field which gives thermal voltage. This thermally generated voltage is directly proportional to the temperature difference created across the semiconductor. The polarity of the thermoemf was positive at the hot end with respect to the cold end which conformed that CdS films are of n- type. The thermoemf (Figure 7) was measured as a function of temperature in the range between 50 and 150 °C. The variation of the thermoemf with temperature difference for all the samples is shown in Figure. 7.

4. 6. 2. Electrical conductivity

Conductivity was given by relation

$$\sigma = \sigma_0 \exp (- \Delta E/kT) \quad \text{-----} (3)$$

where:

σ = conductivity

σ_0 = conductivity constant

k = Boltzmann constant

T = Temperature

Fig. 8. Variation of $\log(\sigma)$ with $1000/T$ (K^{-1}).

The conductivity of each sample is observed to be increasing with an increase in temperature. The increase in conductivity with increase in temperature could be attributed to negative temperature coefficient of resistance and semiconducting nature of nanocrystalline CdS. Variation of conductivity with operating temperature (Fig. 8) clearly indicates that the pure nanocrystalline CdS films are semiconducting in nature.

4. 7. Photoconducting application of nanocrystalline CdS thin film in dark and illuminated light with filter and without filter.

Fig. 9. Variation of photocurrent with in dark light and illuminated light.

From Figure 9 it was observed that, under dark condition photocurrent is low but it increases when illuminated by light source.

Fig. 10. Variation of wavelength with photocurrent with and without filter.

Above graph shows (Fig. 10) variation of photocurrent for different wavelength of light. It is observed that photocurrent at 530 nm (green colour) is maximum as compared to other wavelength of light. Finally, it is concluded that intensity of green light is maximum.

5. CONCLUSIONS

- 1) Nanocrystalline CdS thin films were prepared by simple and inexpensive chemical bath deposition technique.
- 2) The physical, structural, surface morphological and microstructural properties confirm that the as-prepared CdS thin films are nanocrystalline in nature.
- 3) XRD study shows the mixed phase of CdS.
- 4) The elemental analysis conferred that as prepared thin films were nonstoichiometric in nature.
- 5) As the chemical bath deposition temperature increases, thickness of the films, crystalline size and grain size goes on increasing while activation energy goes on decreases.
- 6) Electrical conductivity of the nanocrystalline CdS thin films were observed to be increased with increase in temperature.
- 7) TEP measurement indicate that as prepared CdS thin films were n-type in nature.
- 8) Photoconducting properties shows that as illuminated photocurrent is large as compared to dark current.

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